

Freeform Search

Database:	US Pre-Grant Publication Full-Text Database	
	US Patents Full-Text Database	
	US OCR Full-Text Database	
	EPO Abstracts Database	
	JPO Abstracts Database	
	Derwent World Patents Index	
	IBM Technical Disclosure Bulletins	
Term:	5532094.pn.	
Display:	10	Documents in Display Format: -
Generate:	<input type="radio"/> Hit List <input checked="" type="radio"/> Hit Count <input type="radio"/> Side by Side <input type="radio"/> Image	

Search History

DATE: Thursday, February 05, 2004 [Printable Copy](#) [Create Case](#)

<u>Set</u> <u>Name</u>	<u>Query</u>	<u>Hit</u> <u>Count</u>	<u>Set</u> <u>Name</u> result set
side by side			
DB=PGPB,USPT; PLUR=YES; OP=ADJ			
L24	L22 and polish	0	L24
L23	L22 and polishing	0	L23
L22	5532094.pn.	1	L22
L21	5232094.pn.	1	L21
L20	112 and (solution or slurry) near10(halogen or polyhalide)	63	L20
L19	112 and (halogen or polyhalide) near3 ion	84	L19
L18	L17	0	L18
L17	112 and (hologen or polyhalide) near3 ion	0	L17
L16	112 and (halogen or polyhalide)	1294	L16
DB=USPT,PGPB,JPAB,EPAB,DWPI,TDBD; PLUR=YES; OP=ADJ			
L15	L14 not L13	111	L15
L14	L12 and L10	123	L14
L13	L12 and L11	12	L13
L12	(51/307 51/308 51/309 OR 106/3 OR 252/79.1 252/79.2 252/79.3 252/79.4 252/79.5 OR 438/692 438/693 OR 216/\$)!.CCLS.	25226	L12

<u>L11</u>	L10 and edta (iodine or bromine or fluorine or sulfuric or hydrochloric or carbonic or iodide)	166	<u>L11</u>
<u>L10</u>	and ((polymer near2 particle or abrasive) same (polystyrene or polytetrafluoroethylene or polyamide or silver or porous silica or porous silicon))	2231	<u>L10</u>
<u>L9</u>	L6 and (surfactant or passivating or triazole or benzotriazole or chelating or edta or ethylenediaminetetraacetic or polymer)	24	<u>L9</u>
<u>L8</u>	polishing near20 (solution near5 (iodine or bromine or fluorine or sulfuric or hydrochloric or carbonic or iodide)) and (polystyrene or polytetrafluoroethylene or polyamide or silver or porous silica or porous silicon)	67	<u>L8</u>
<i>DB=USPT,PGPB; PLUR=YES; OP=ADJ</i>			
<u>L7</u>	polishing near20 (solution near5 (iodine or bromine or fluorine or sulfuric or hydrochloric or carbonic or iodide)) and (polystyrene or polytetrafluoroethylene or polyamide or silver or porous silica or porous silicon)	59	<u>L7</u>
<u>L6</u>	L5 not L4	46	<u>L6</u>
<u>L5</u>	(51/307 51/308 51/309 OR 106/3 OR 252/79.1 252/79.2 252/79.3 252/79.4 252/79.5 OR 438/692 438/693 OR 216/\$)!CCLS. and polishing near20 (solution near5 (iodine or bromine or fluorine or sulfuric or hydrochloric or carbonic or iodide))	55	<u>L5</u>
<u>L4</u>	(51/307 51/308 51/309 OR 106/3 OR 252/79.1 252/79.2 252/79.3 252/79.4 252/79.5 OR 438/692 438/693 OR 216/\$)!CCLS. and polishing near20 (solution near5 (iodine or bromine or fluorine or sulfuric or hydrochloric or carbonic or iodide)).clm.	9	<u>L4</u>
<u>L3</u>	L2 and (polytetrafluoroethylene or polyamide or silver or porous silica or porous silicon) near10 (particle or abrasive)	29	<u>L3</u>
<u>L2</u>	(51/307 51/308 51/309 OR 106/3 OR 252/79.1 252/79.2 252/79.3 252/79.4 252/79.5 OR 438/692 438/693 OR 216/\$)!CCLS. and solution near5 (iodine or bromine or fluorine or sulfuric or hydrochloric or carbonic or iodide)	1397	<u>L2</u>
<u>L1</u>	(51/307 51/308 51/309 OR 106/3 OR 252/79.1 252/79.2 252/79.3 252/79.4 252/79.5 OR 438/692 438/693 OR 216/\$)!CCLS. and solution near5 (iodine or bromine or fluorine or sulfuric or hydrochloric or carbonic or iodide)	1330	<u>L1</u>

END OF SEARCH HISTORY